2.5D/3D Systems with Silicon Photonic NoCs: Efficient Thermal Management, Opportunities, and Challenges

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Today's Multi-/Many-core Computing Systems

• Due to technology scaling & high computation needs, more resources are integrated on-chip Intel SCC



Original data up to the year 2010 collected and plotted by M. Horowitz, F. Labonte, O. Shacham, K. Olukotun, L. Hammond, and C. Batten New plot and data collected for 2010-2015 by K. Rupp

[Rupp, 40 years of microprocessor trend data, 2015]

(48 cores, 2010)

3D Stacking Technology & Its Benefits

- 3D stacking technology is a promising integration technology for future computation system design
 - More on-chip resources compared to 2D designs



- Various technologies integrated on a single chip
 - On-chip stacking DRAM
 - Silicon-photonic Network-on-Chip (PNoC)



http://researcher.watson.ibm.com/researcher/view_group.php?id=2757

Challenges of 3D Stacking Technology

- On-chip Resource Management
 - Under utilized resources ->
 Performance and energy efficiency Layer0
 benefits left on the table
 - Increased power density →
 Potential thermal violations
- On-chip Thermal Management
 - Thermal and process sensitivity of devices in other technologies →
 Resilience problems or high power consumption



http://researcher.watson.ibm.com/researcher/view_group.php?id=2757

Layer0 Layer1 Layer2 LayerN Core Cache

Silicon-Photonics Network-on-Chip

• Silicon-Photonic Link



- Silicon-Photonic Links vs. Electrical Links
 - Higher bandwidth density
 - Lower long-distance communication latency
 - Lower data-dependent energy consumption

- More sensitive to thermal variations
- More sensitive to process variations

Silicon-Photonics Network-on-Chip

• Silicon-Photonic Link





• Silicon-Photonic Links vs. Electrical Links

 Higher bandwidth density



 Lower data-dependent energy consumption



- thermal variations
- More sensitive to process variations
- High optical loss
- Low laser source efficiency (due to high temp.)

High thermal tuning power

High laser source power

On-chip energy efficiency is a limiting factor for PNoC integration!

Manycore Systems with Silicon-Photonics NoCs



How do we address thermal sensitivity today?

Device-Level Techniques

- Cladding [Djordjevic, Opt.Exp.'13]
- Heaters [*Zhou*, *TACO'10*] [*Li*, *TVLSI'12*]



Mach-Zehnder interferometers
 [Biswajeet, Opt.Exp.'10]

Runtime Management Techniques

- Aurora [Li, TCAD'15]
 - o Thermal Tuning
 - \circ DVFS
 - Routing Algorithm

Design-Time Techniques

• Studies on PNoC placement's impact on signal to noise ratio [Li, DATE'15]



 Optical waveguide routing algorithms to reduce optical loss under a fixed netlist [Condrat, SLIP'08]
 [Ding, DAC'09] [Ramini, DATE'13]





- P & R Solutions for PNoC
 - PROTON: An automatic tool for PNoC P & R [Boo, ICCAD'13]
 - GLOW: A ILP based global router for PNoC [Ding, DAC'12]

Our work aims at *reducing the thermal tuning power & laser source power* for PNoC via workload allocation, thermal tuning policies, and design-time techniques.

Cross-Layer Design Automation

Tooling for Design Space Exploration



[DATE'14]

Target Many-core System w/ PNoC[DATE'14, TCAD'17]



Floorplan Optimization Flow



• Optimization Goal: Minimize: $\alpha \cdot P_{PNoC} + \beta \cdot AREA_{PNoC}$

$$P_{PNoC} = P_{laser} + P_{tuning} + P_{electrical}$$

- PNoC Power:
 - P & R's impact on waveguide length, crossing and bending
 - Laser source efficiency
 - PNoC placement's impact on thermal tuning power
- PNoC Area:
 - Area cost of router groups and waveguides

[DATE'16]

Floorplan Optimization Flow



• Compact thermal model



[DATE'16]

Floorplan Optimization Flow



Compact thermal model

Power profile:



[DATE'16]



Cross-layer PNoC P&R Optimization

Power Profiles

Thermal Conditions of Potential Ring Group Locations

PNoC Layouts w/ Minimum PNoC Power



[DATE'14]

RingAware Workload Allocation Policy

- Goals:
 - Minimize the difference among ring temperatures



- Multi-program support
 - Sort the threads based on their power dissipation & allocate highpower application first

FreqAlign Workload Allocation Policy

- Process variation introduces resonant frequency shift after the system is manufactured
- Only balancing the temperature of ring groups is not enough to compensate the frequency mismatch
- On-chip laser sources' optical frequencies also need to match with corresponding rings' resonant frequency

(3)

4

(3)

(3)

(3)

4

(4)

4

(2

(2)

(2)

(1)

(1)



[TCAD'17]

Laser source

Ring Group 1

Ring Group 2

Ring Group 3

Actual optical freq. (Process Variation) Optical freq. after each thread allocation

Thread index

Designed

optical freq.

Using tuning to adjust optical freq.

Optical freq. after tuning

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FreqAlign Workload Allocation Policy

• Target many-core system:



- FreqAlign:
 - Keep track of the optical frequency shifts of ring groups (in **RG weight array**)
 - Record every core's thermal impact on every ring group
 - Choose the core to minimize the frequency difference among all ring groups

• Workflow:



[TCAD'17]

Experimental Methodology

• Simulation Framework:



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• Workload Sets: Selected benchmarks from SPLASH2, PARSEC and UHPC:

Workload Sets	Job 1	Job2
HP + HP	md	shock
HP + MP	md	blackscholes
HP + LP	shock	lu_cont
MP + MP	barnes	blackscholes
MP + LP	barnes	water_nsq
LP + LP	lu_cont	canneal

Workload Allocation Policy:
 Cluster, RingAware, FreqAlign

Tested Policies:

 Thermal Tuning Policy: Target
 Frequency Tuning (TFT),
 Adaptive Frequency Tuning (AFT)

Experimental Results for Many-core System w/o Process Variations



- Compared to *RingAware, FreqAlign* reduces the resonant frequency difference by **60.6%** on average;
- Compared to *RingAware + TFT, FreqAlign + AFT* reduces the tuning power by 14.93W on average.

[NOCS'14]

Laser Source Placement and Sharing Examples



	Edge Placement	Local Placement
Sharing Degree	High	Low
Propagation loss	High	Low

Higher Sharing Degree

- → Higher η_{WPE} , Lower # of laser sources
- \rightarrow Lower laser source power consumption

Higher Propagation loss

- \rightarrow Higher required output optical power
- ightarrow Higher laser source power consumption

Take-Aways

- Cross-layer, thermally-aware optimizer for floorplanning of PNoCs
- Runtime workload allocation for thermal tuning power reduction
- Cross-layer simulation & optimization flow: an enabler to design energy-efficient systems with PNoCs





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